



IN THE SPECIFICATION

Please replace the paragraph beginning at page 4, line 10, with the following rewritten paragraph:

first and second recording layers faced to each other and supported by the transparent substrate, the first recording layer having a non-erasable information zone on which a pit array is formed as non-erasable information and a first recordable zone on which a recording mark array is formed with an irradiation of the focused light beam passing through the transparent substrate, the second recording layer having a non-recording zone on which data is prevented from being ~~re-coded~~ recorded and a second recordable zone on which a recording mark array is formed with the irradiation of the focused light beam, and the non-recording zone being faced to the non-erasable information zone and including an illumination region on which a beam spot is formed by the light beam focused on the non-erasable information zone.

Please replace the paragraph beginning at page 5 line 6, with the following rewritten paragraph:

first and second recording layers faced to each other and supported by the transparent substrate, the first recording layer having a non-erasable information zone on which a pit array is formed as non-erasable information and a first recordable zone on which a recording mark array is formed with the irradiation of the focused light beam passing through the transparent substrate, the second recording layer having a non-recording zone on which data is prevented from being ~~re-coded~~ recorded and a second recordable zone on which a recording mark array is formed with the irradiation of the focused light beam, the non-recording zone being faced to the non-erasable information zone and including an illumination region on which a beam spot is formed by the light beam focused on the non-erasable information zone, and the non-erasable information zone includes address information for specifying the non-recording zone on the second recording layer; and

Please replace the paragraph beginning at page 7, line 3, with the following rewritten paragraph:

An optical disk 100 shown in FIG. 1 is of a rewritable type, and has a multi-layered structure, that is, has two recording layers 102, 103. In the optical disk 100, the 0 recording layer 102 and first recording layer 103 are buried in a transparent optical disk substrate 101 so that the recording layers are disposed opposite to each other at a micro interval. Here, the 0 recording layer 102 is disposed at an incident surface side of the disk 100 and the first recording layer 103 is disposed at the opposite surface side of the disk 100. That is, the 0 recording layer 102 is disposed further in the vicinity of the objective lens as compared with the first recording layer 103, and both of the layers are faced to an incident direction X of a light beam. Thus, the light beam emerged from the objective lens (not shown in FIG. 1) is incident on the incident surface of the disk, passes through the substrate ~~102~~101, and focused on the 0 recording layer 102 to search the 0 recording layer 102. The first recording layer 103 is disposed between the opposite surface of the disk and the 0 recording layer 102. Thus, the light beam passing through the 0 recording layer 102 is also focused on the first recording layer 103 to search the first recording layer ~~102~~103.

Please replace the paragraph beginning at page 9, line 1, with the following rewritten paragraph:

As shown in FIG. 1, in the innermost peripheral read-in area of the 0 recording layer 102, a read-in emboss-area 105 is provided, in which information or data of the attribute and use condition of the optical disk, such as physical format information, is recorded as non-erasable information. Different from the groove area, no groove is formed in the read-in emboss-area 105, and a pit array is continuously formed in the area. The groove area is formed as the rewritable data zone adjacent to the read-in emboss-area 105, that is, outside the read-in emboss-area 105.

Please replace the paragraph beginning at page 9, line 12, with the following rewritten paragraph:

In the disk shown in FIG. 1, the groove area 104-0 is formed to an outermost periphery from an outer periphery of the read-in emboss-area 105 in the 0 recording layer 102, and the groove area 104-1 is formed to an innermost peripheral area from the outermost periphery of the first recording layer 103. On the contrary, the first recording layer 103 has no read-out emboss-area. Thus, the groove area 104-1 is continuously formed from the innermost peripheral area to the outermost periphery in the first recording layer 103. The inner peripheral area having no read-out emboss-area in the first recording layer 103 is faced to the read-in emboss-area 105 of the 0 recording layer 102 as shown in FIG. 1, which is [[a]] different from a structure of ROM having double-layers. Since the first recording layer 103 has no read-in emboss-area, even if the inner peripheral area of the first recording layer 103 is defined as the read-out area, the inner peripheral area of the first recording layer 103 has substantially the same physical characteristics as those of the other groove area 104-1.